

were determined by high-resolution transmission electron microscopy to be conformal, uniform, continuous, and dense, with a controllable thickness between a few Ångströms and a few nanometers. After drying the samples for 4 h at 150°C, the team then used them to fabricate DSSCs. While niobia coatings did not improve the

cell performance, cells based on electrodes with amorphous titania coatings were up to 65% more efficient than non-coated reference cells, and bi-layer titania/magnesia coatings led to up to 113% efficiency gains. The researchers attributed the enhancements to improved inter-particle connections from the titania layer and reduced

recombination rates due to the insulating properties of the magnesia layer.

These results suggest that enhanced DSSCs fabricated by a low-cost, low-temperature technique may one day offer a competitive alternative to conventional silicon photovoltaics.

COLIN MCCORMICK

High Modulus Fluorinated Molding Materials Improve Fidelity in Soft Lithography

Molding materials used for soft lithography, a nanofabrication technique, just got a little tougher. Polydimethylsiloxane (PDMS) elastomers, typically used as a molding material to replicate feature sizes greater than 100 nm, tend to have a low elastic modulus (2.0 MPa) and low surface energy (~25 mN/m). These properties make it easy to remove the PDMS from delicate master templates. New findings, however, show that increasing a material's elastic modulus may help improve pattern transfer fidelity, especially when replicating high aspect ratio features with small spacing or periodicity. A research team including S.S. Williams and co-researchers at the University of North Carolina at Chapel Hill, S. Retterer at Oak Ridge National Laboratory, R. Ruiz of Hitachi Global Storage Technologies, and J.M. DeSimone at the University of North Carolina at Chapel Hill and North Carolina State University reported in the April 14 issue of *Nano Letters* (DOI: 10.1021/nl100326q; p. 1421) a composite molding technique that utilizes perfluoropolyether-(PFPE)-based elastomers. Williams and colleagues found that by increasing the modulus of the PFPE, smaller feature sizes could be replicated than when molds were made with PDMS.

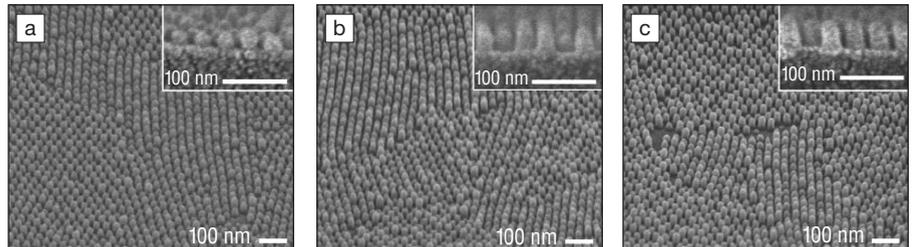


Figure 1. Trimethylolpropyl triacrylate (TMPTA) patterns formed using a variety of composite molds. TMPTA patterns made with molds composed of a low modulus material (1.4 K perfluoropolyether, PFPE) (a) demonstrated a loss in resolution while TMPTA patterns from molds made with higher modulus materials such as (b) 80:20 1.4 K PFPE/TMPTA blend and (c) PFPE-tetramethacrylate showed much higher fidelity.

“The key to high fidelity molding materials,” said Williams, “is that you need a combination of a high modulus material that retains a low surface energy.” The team systematically examined the macromonomer functionality (i.e., the number of acrylate groups per polymer chain), the molecular weight of the macromonomer, and the addition of a multifunctional crosslinking additive (trimethylolpropyl triacrylate, TMPTA). Molds with higher functionality, lower molecular weight macromonomers, or TMPTA partially substituted for PFPE showed dramatic improvements in modulus with an insignificant bump in surface energy (see Figure 1). The molds with higher modulus had

lower propensity for lateral collapse of high aspect ratio features.

Overall, the new PFPE molds improved fidelity of pattern transfer from the master to the mold and from the mold to TMPTA replicates. While previously reported PDMS molds were able to replicate 80 nm × 80 nm feature sizes with 100 nm heights, the PFPE molds were able to replicate 20 nm × 20 nm feature sizes with 40 nm heights in TMPTA. The researchers also note the ability to easily tailor the height of the flash layer, a feat that is difficult to obtain without the use of expensive equipment.

KEVIN P. HERLIHY

Magnetic Field Applied to 3D Manipulation of Alloys

The relentless drive toward increased miniaturization and better performance of microelectronic devices has necessitated three-dimensional (3D) architectures with vertical geometries. Such 3D architectures require stacked two-dimensional layers formed by photolithography or perpendicular vias for the conductive pathways. Various new approaches have been proposed to obtain such structures, including self-assembly and ink-jet printing; however, these use processes and

materials not commonly found in current microelectronics fabrication facilities.

A different issue is the current use of lead-based solders as joining materials, serving as interconnects in devices. Due to serious health concerns associated with the use of lead-based solders, lead-free alternatives are being explored, such as Sn-3.5%Ag, and are being mandated through regulations such as the Restrictions on Hazardous Substances (RoHS). Unfortunately, this lead-free material has processing temperatures 30–40°C above the melting point of 220°C,

of the incumbent SnPb alloy, which can significantly affect device performance. Now, A.G. Ramirez and her co-workers at Yale University report in the March 16 issue of the *Proceedings of the National Academy of Sciences* (DOI: 10.1073/pnas.1001410107; p. 4834) the development of tin-silver-based alloys containing iron dispersions that can be inductively heated and remotely manipulated in 3D space using a magnetic field. The iron dispersions allow for magnetically driven inductive non-contact heating, while at the same time imparting mechanical strength.